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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/813,767	03/31/2004	Hankyu Moon	NECL-04-001	5251
Jeffery J. Brosemer, Ph.D., ESQ. 138 S. Telegraph Hill Road			EXAMINER	
			BITAR, NANCY	
Holmdel, NJ 07733			ART UNIT	PAPER NUMBER
			2624	
			MAIL DATE	DELIVERY MODE
			04/08/2008	DADED

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

# Application No. Applicant(s) 10/813,767 MOON ET AL. Office Action Summary Examiner Art Unit NANCY BITAR 2624 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 28 March 2008. 2a) ☐ This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 1 and 3-6 is/are pending in the application. 4a) Of the above claim(s) 6 is/are withdrawn from consideration. 5) Claim(s) \_\_\_\_\_ is/are allowed. 6) Claim(s) 1 and 3-5 is/are rejected. 7) Claim(s) \_\_\_\_\_ is/are objected to. 8) Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) ☐ The drawing(s) filed on 31 March 2004 is/are: a) ☐ accepted or b) ☐ objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some \* c) None of: Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). \* See the attached detailed Office action for a list of the certified copies not received. Attachment(s)

1) Notice of References Cited (PTO-892)

Notice of Draftsperson's Patent Drawing Review (PTO-948)

Information Disclosure Statement(s) (PTO/S5/08)
Paper No(s)/Mail Date \_\_\_\_\_\_

Interview Summary (PTO-413)
Paper No(s)/Mail Date.

6) Other:

5) Notice of Informal Patent Application

#### DETAILED ACTION

### Response to Arguments

 Applicant's arguments, in the RCE filed 03/28/2008, with respect to the rejections of claims 1 and 3-5 under 35 U.S.C102 (b) have been fully considered but are moot in view of the new ground(s) of rejection necessitated by the amendments. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made in view of Nicponski et al (US 7.274.832).

#### Examiner Notes

2. Examiner cites particular columns and line numbers in the references as applied to the claims below for the convenience of the applicant. Although the specified citations are representative of the teachings in the art and are applied to the specific limitations within the individual claim, other passages and figures may apply as well. It is respectfully requested that, in preparing responses, the applicant fully consider the references in entirety as potentially teaching all or part of the claimed invention, as well as the context of the passage as taught by the prior art or disclosed by the examiner

## Information Disclosure Statement

3. The listing of references in the spec paragraph [0005] has not been considered. The listing of references in the specification is not a proper information disclosure statement. 37 CFR 1.98(b) requires a list of all patents, publications, or other information submitted for consideration by the Office, and MPEP § 609.04(a) states, "the list may not be incorporated into

Page 3

Application/Control Number: 10/813,767

Art Unit: 2624

the specification but must be submitted in a separate paper." Therefore, unless the references have been cited by the examiner on form PTO-892, they have not been considered.

# Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 1, 3-5 are rejected under 35 U.S.C. 103(a) as being unpatentable over Li et al (Y.Li, S.Gong, and H. Liddell in an article entitled "Support vector regression and classification based on multi-view face detection and recognition", which was presented at FG2000) in view of Nicponski et al (US 7,274,832).

As to claim 1, Li et al teaches a method of estimating a pose of a human head in natural scenes comprising the steps of: generating, a sparse representation of a human face by transforming a raw facial image into sets of vectors representing fits of the face comprising fits of whole facial features that represent the geometry (position, size and orientation) of the features, to a random sparse set of model configurations (section 2; support vector machine); training, the sparse representation to a set of face(s) in known poses (filter captures the changes both in horizontal and vertical directions which correspond to yaw and tilt changes respectively the filtered pattern are more representative than the original images; section 3.1 and figure 4 is a sample of training faces); and determining, a pose of a head by comparing the trained representation(s) to a facial image ( the first 10 PCs and the reconstructed pattern from the first

Application/Control Number: 10/813,767

Art Unit: 2624

20 PCs are compared to the original images and the filtered patterns, section 3.1; estimation head pose using SVR). Note that the two Sobel operators detect the edge pf the face pattern which is reduced feature of the face (section 3.1) which is the spare set. While Li et al meets a number of the limitations of the claimed invention, as pointed out more fully above, Li fails to specifically teach the sparse representation is a collection of projection to a number of randomly generated possible configurations of the human face.

Specifically, Nicponski et al. teaches an face detection algorithm S was subject to standardize face region size, decompose face region into sub-regions, ignore dependencies between sub-regions, project sub-regions to lower dimension representation using PCA, code projections using sparse coefficients, quantize sparse coefficients, decompose appearance and position, ignore position for uncommon patterns, and vector quantize positional dependence for common patterns and wherein the <a href="sparse">sparse</a> coding scheme is further complicated by grouping the last six coefficients pair-wise into groups and considering their sum square values when selecting the six <a href="projection">projection</a> dimensions to retain. In this way, twelve coefficients are reduced to six for subsequent. It would have been obvious to one of ordinary skill in the art to use the sparse representation as a collection of projection of the human face in Li algorithm in order to provide a best estimated image and capture enough information for accurate recognition. Therefore, the claimed invention would have been obvious to one of ordinary skill in the art at the time of the invention by applicant.

Application/Control Number: 10/813,767

Art Unit: 2624

As to claim 3, Li et al teaches the method according to claim 2 wherein the transforming step further comprises the step of: collecting, salient features of the face image which are useful to estimate the pose of the face (nose bone, soft boundaries, face characteristics; section 3.2).

As to claim 4, Li et al teaches the method according to claim 3 wherein the transforming step further comprises the step of: suppressing, irrelevant variations of face appearance (figure 2 and section 3.2 and 4.3; note that PCA keeps essential features of recognition in order to remove the redundancy with respect to probability and gradient).

As to claim 5, Li et al teaches method according to claim 4 wherein the training step further comprises the step of: learning, using Support Vector Regression (SVR), a relation between the sparse representation and the pose(s) (estimating the pose using SVR pose estimator, section 3 and 3.1).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to NANCY BITAR whose telephone number is (571)270-1041. The examiner can normally be reached on Mon-Fri (7:30a.m. to 5:00pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bhavesh Mehta can be reached on 571-272-7453. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Application/Control Number: 10/813,767 Page 6

Art Unit: 2624

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Andrew W. Johns/ Primary Examiner, Art Unit 2624

Nancy Bitar

3/31/2008